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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Applicant

Young-Joon Park, et al.

Docket Number: TI-35623

Serial No.: 10/628,198

Art Unit: 2814

Filed: 07/28/03

Examiner: Ginette Peralta

For:

A Two-Step Semiconductor Manufacturing Process for

Copper Interconnects

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